

TRANSMITTAL OF FORMAL DRAWINGS

Docket No.
G0186

In Re Application Of: Wang et al.

APR 18 2002

Serial No.
10/053,256Filing Date
01/18/2002

Batch No.

Examiner

Art Unit
2185

Invention: TWO-STEP SOURCE SIDE IMPLANT FOR IMPROVING SOURCE RESISTANCE AND SHORT CHANNEL EFFECT IN DEEP SUB-0.18um FLASH MEMORY TECHNOLOGY

Address to:

Assistant Commissioner for Patents
Washington, D.C. 20231

Transmitted herewith are:

Six (6) sheets of formal drawing(s) for this application.

Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).

RECEIVED

APR 23 2002

Technology Center 2100

1C CUST/MAIL ROOM
REC'D 21 JUN 2002

H. Donald Nelson

Signature

H. Donald Nelson, Reg. No. 28,980

Dated: 4/10/02

I certify that this document and attached formal drawings are being deposited on 4/10 with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and addressed to the Assistant Commissioner for Patents, Washington, D.C. 20231.

N. Donald Nelson
Signature of Person Mailing Correspondence

H. Donald Nelson

Typed or Printed Name of Person Mailing Correspondence